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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/693,842	10/24/2003	Mamiko Nomura	03310/034001	9997
75	90 04/20/2005		EXAMINER	
ROSENTHAL Suite 2800	& OSHA L.L.P.	HAMPTON HIGHTOWER, PATRICIA		
1221 McKinney Street			ART UNIT	PAPER NUMBER
Houston, TX			1711	
			DATE MAILED: 04/20/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

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# Supplemental Notice of Allowability

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Application No.	Applicant(s)		
10/693,842	NOMURA MAMIKO ET AL		
Examiner	Art Unit		
Patricia Hightower	1711		

	Patricia Hightower	1711	
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGOT OF THE OFFICE	OR REMAINS) CLOSED in this or other appropriate communica GHTS. This application is subjection in the subjection is subjection.	s application. If not incl ation will be mailed in d	uded ue course. <b>THIS</b>
1. X This communication is responsive to the amendment/repso	nse filed November 30, 2004.		
2. The allowed claim(s) is/are <u>1-7</u> .			
3. $\square$ The drawings filed on <u>24 October 2003</u> are accepted by the	Examiner.		
<ul> <li>4.  Acknowledgment is made of a claim for foreign priority units a)  All b)  Some* c)  None of the: <ol> <li>Certified copies of the priority documents have</li> <li>Certified copies of the priority documents have</li> <li>Copies of the certified copies of the priority documents have</li> <li>International Bureau (PCT Rule 17.2(a)).</li> </ol> </li> <li>* Certified copies not received:</li> </ul> Applicant has THREE MONTHS FROM THE "MAILING DATE" of the priority units and priority documents have	been received. been received in Application N uments have been received in of this communication to file a re	o this national stage appl	
noted below. Failure to timely comply will result in ABANDONMI THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  5. A SUBSTITUTE OATH OR DECLARATION must be submit to the submit of the submi	ited. Note the attached EXAMII		or NOTICE OF
INFORMAL PATENT APPLICATION (PTO-152) which give  6. CORRECTED DRAWINGS ( as "replacement sheets") must  (a) including changes required by the Notice of Draftsperso  1) hereto or 2) to Paper No./Mail Date  (b) including changes required by the attached Examiner's  Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR 1.6 each sheet. Replacement sheet(s) should be labeled as such in the  7. DEPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT F	be submitted. on's Patent Drawing Review (Formula Amendment / Comment or in the day of t	PTO-948) attached the Office action of rawings in the front (not 121(d).  AL must be submitted	·
Attachment(s)  1. Notice of References Cited (PTO-892)  2. Notice of Draftperson's Patent Drawing Review (PTO-948)  3. Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Sumn Paper No./Mai 3), 7. ☒ Examiner's Am	I Date endment/Comment tement of Reasons for A	,

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### Examiner's Amendment

In The Claims:

Claim 4, line 1, delete Claim 5 and insert therefor Claim 3.

Support:

Said Examiner's Amendment has been implemented to correct an obvious error in the dependency of claim 4 (improperly depended from Claim 5).

### Reasons For Allowance

The following is an examiner's statement of reasons for allowance:

In view of the applicants' response filed November 30, 2004 in which it was established that the prior art did not teach as claimed the resin composition containing a polyimide precursor denoted by formula (1) and a photosensitizer, wherein A<sup>2</sup> in formula (1) is an alicycllic compound selected from either one of cyclohexane denoted by the chemical formula (3) or 4,4'-methylenebiscyclohexane denoted by the chemical formula (4), and wherein the polyimide precursor has an imidization degree of 7.5% or more and 36% or less as determined by equation (a); Equation (a) :  $(PS_1/PS_2)$  /  $(PI_1/PI_2)$  x 100, wherein  $PS_1$  and  $PI_1$  represent the absorbance of the imide ring before and after complete imidization, PS<sub>2</sub> and PI<sub>2</sub> represent the absorbance of the chemical structure A<sup>2</sup> in formula (1) before and after complete *imidization*; wherein imidization of no less than 7.5% in the polyimide precursor is selected to have good resistance to the developing solution of the unirradiated portion of the polyimide precursor while imidization of no more than 36% in the polyimide precursor is selected so that a resin film can be easily prepared from the composition; a. process of forming a resin film formed from the resin composition comprising the

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polyimide precursor denoted by formula (1) comprising coating an object with the resin film exposing the resin film to light to form a latent image, developing the resin film and heating to imidize the polyimide precursor; and methods for preparing a resin composition comprising (i) reacting 1,4-diaminocyclohexane or 4,4'-methylenebis(cyclohexylamine) with an aromatic dianhydride in a solvent to form a salt, (ii) reacting a resin solution containing the salt at a temperature of 80°C – 150°C, (iii) reacting the resin solution at a temperature of 160°C – 250°C to a desired imidization degree and (iv) adding a photosensitizer to the resin solution to give a resin composition all are allowable.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

#### Prior Art

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. These references are cited to show the state of the art of photosensitive resin compositions containing polyimide precursor/polyamic acid and a photoacid generator/ photosensitizer; Jung, Tokoh and Maeda.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Patricia Hightower whose telephone number is (571) 272-1073. The examiner can normally be reached on M-F from 9:30 A.M. - 6:00 P.M.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, James Seidleck can be reached on (571) 272-1078. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

P. Hampton Hightower Primary Examiner Art Unit 1711

P. Hightower: ph February 19, 2005 March 22, 2005